

Docket No.: P2002,0805

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : JENSPETER RAU ET AL.  
Filed : CONCURRENTLY HEREWITH  
Title : PHOTSENSITIVE COATING MATERIAL FOR A SUBSTRATE  
AND PROCESS FOR EXPOSING THE COATED SUBSTRATE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. 1.98 copies of the following patents and/or publications are submitted herewith:

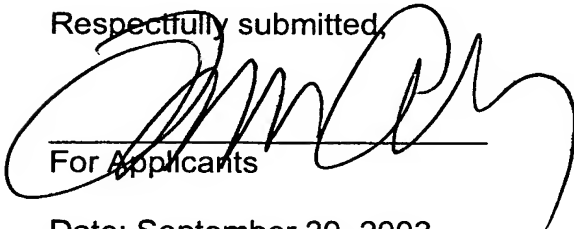
Plummer, J. D. et al.: "Silicon VLSI Technology", Prentice Hall Inc., 2000, pp. 221-226;

DeMent, J.: "Handbook of Chemistry and Physics", CRC Press, 55<sup>th</sup> Edition, 1974-1975, pp. D117-D118;

Widmann, D. et al.: "Technologie hochintegrierter Schaltungen" [Technology of Highly Integrated Circuits], Springer-Verlag, 1996, pp. 104-173.

If no translation of pertinent portions of any foreign language patents or publications mentioned above is included with the aforementioned copies of those applications, patents and/or publications, it is because no existing translation is readily available to the applicant.

Respectfully submitted,



For Applicants

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Date: September 29, 2003

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<b>FORM PTO-1449 (SUBSTITUTE)</b>  U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE  <b>INFORMATION DISCLOSURE          STATEMENT BY APPLICANT</b> (37 CFR 1.98(b))				Attorney Docket No.: P2002,0805 Appl. No.: _____  Applicant: JENSPETER RAU ET AL.  Filing Date: September 29, 2003 Group Art Unit: _____			
EXAMINER INITIALS		PATENT NO.	DATE	PATENTEE	CLASS	SUB CLASS	FILING DATE
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<b>FOREIGN PATENT DOCUMENT</b>							
		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB CLASS	TRANSL. YES   NO
	J						
	K						
	L						
	M						
	N						
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)</b>							
		Plummer, J. D. et al.: "Silicon VLSI Technology", Prentice Hall Inc., 2000, pp. 221-226					
		DeMent, J.: "Handbook of Chemistry and Physics", CRC Press, 55 <sup>th</sup> Edition, 1974-1975, pp. D117-D118					
<b>EXAMINER</b>				<b>DATE CONSIDERED</b>			

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